

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	Toru KIMURA <i>et al.</i>	Confirmation No.:	4887
Application No.:	10/586,187	Examiner:	Johnson, Connie P.
Filed:	July 31, 2007	Group Art Unit:	1722

For: UPPER LAYER FILM FORMING COMPOSITION FOR LIQUID IMMERSION  
AND METHOD OF FORMING PHOTORESIST PATTERN

Commissioner for Patents  
Alexandria, VA 22313-1450

**AMENDMENT UNDER 37 C.F.R. § 1.111**

Dear Sir:

In response to the Office Action dated June 23, 2011, please amend this application as follows.

AMENDMENT AND PRESENTATION OF CLAIMS .....	2
REMARKS .....	6